## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Song et al.	) Group Art Unit: 1752 )
Serial No.:10/720,966	) Examiner: John S. Y. Chu )
Filed: November 24, 2003	) Confirmation No.: 5221
For: PHOTORESIST COMPOSITION AND METHOD PATTERN FORMING USING THE SAME	) TKHR Docket: 250913-1030 ) Top-Team: 0424-8857US )

## RESPONSE TO FINAL OFFICE ACTION WITH RCE

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

The FINAL Office Action mailed November 14, 2006, and Advisory Action mailed April 16, 2007, have been carefully considered. In response thereto, Applicants hereby submit following amendments and remarks. Reconsideration and allowance of the application and presently pending claims, as amended, are respectfully requested.